

AM-FPD '10 Time Table

	Monday, July 5		Tuesday, July 6		Wednesday, July 7	
Registration	8:30-17:00		8:30-17:00		8:30-14:00	
Workshop	9:30- 9:45	Opening Session	9:00-10:50	Symposium (1) Thin Film Materials and Devices for Next Generation	9:00-10:25	Session 6 : Solar Cell
	9:45-10:45	Session 1 : Keynote Address				
	10:45-11:00	<i>Coffee Break</i>	10:50-11:05	<i>Coffee Break</i>	10:25-10:40	<i>Coffee Break</i>
	11:00-12:30	Session 2 : New Display Technologies	11:05-12:35	(1) Thin Film Materials and Devices for Next Generation (Continued)	10:40-12:05	Session 7 : Poly-Si TFT
	12:30-13:30	<i>Lunch</i>	12:35-13:35	<i>Lunch</i>	12:05-13:00	<i>Lunch</i>
	13:30-15:00	Session 3 : Oxide TFT	13:35-15:05	(2) Technology Trend for Display Devices and Fabrication Technology	13:00-14:20	Session 8 : OLED Displays
	15:00-15:15	<i>Coffee Break</i>	15:05-15:20	<i>Coffee Break</i>		
	15:15-16:00	Session 4 : New Materials for FPDs				
	16:00-16:30	Late News				
Author Interviews	16:40-17:10	<i>Author Interviews</i>	15:20-15:50	<i>Author Interviews</i>	14:30-15:00	<i>Author Interviews</i>
Poster Session			15:20-17:20	Session 5 : Poster Session TFTp/TFMDp/FPDp/LNp		
Tutorial	17:20-19:20	<i>Tutorial in Japanese</i>				
Banquet			17:40-19:40	<i>Banquet</i>		

Registration : "Multi-Purpose Digital Hall" Entrance

Workshop : "Multi-Purpose Digital Hall "

Author Interviews : "Media Hall" (July 5, 7), "Multi-Purpose Digital Hall" (July 6)

Tutorial in Japanese : "Multi-Purpose Digital Hall"

Poster Session : "Media Hall"

Banquet : "Cafeteria" in Tokyo Institute of Technology, 2nd floor